

# Influence of different concentrations of Mg on the photorefractive gain in LiNbO<sub>3</sub>

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**Abstract:** Dependence of photorefractive response on c-axis orientation for LiNbO<sub>3</sub> at several magnesium contents has been observed. When c-axis is perpendicular to the incidence plane the optical damage persists even above threshold and diminished below threshold.

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## 1. Introduction

The photorefractive effect can modify in electro-optic materials, generally under long-time exposition of laser light, the optimum conditions for anharmonic-oscillator-type nonlinear optical applications[1], such as second harmonic generation, self-focusing, and optical bistability between other novel effects. Doping with In, Zn, or Mg the photorefractive response of lithium niobate almost vanishes, giving the opportunity of taking advantage of its Lorentz-oscillator-type nonlinear optical properties[2]. In the particular case of Mg: LiNbO<sub>3</sub> exist a threshold in Mg content for which the photorefractive effect is almost destroyed. This threshold value is around 4.6 mol % MgO in congruent melt[3]. In this work, we have estimated the range comprising the threshold concentration of Mg incorporated in LiNbO<sub>3</sub>. In addition, photorefractive gains at 532 nm for six LiNbO<sub>3</sub> samples at two c-axis orientations with different Mg content levels, using the two-wave coupling technique have been obtained. An outstanding anisotropic behavior of photorefractive inhibition against polar axis orientation is observed.

## 2. Experimental procedure

In this work we investigated six single LiNbO<sub>3</sub> crystals with different Mg concentrations acquired from a commercial supplier. These samples were grown by the conventional Czochralski method in air. They were pulled along the c-axis and so the polar axis was parallel to pulling direction. Atomic absorption spectroscopy was used to measure the amount of Mg incorporated in each crystal. Photorefractive gain as a function of fringe spacing using the two-wave mixing technique in co-propagation configuration was also obtained. The laser light polarization was vertical, i.e. perpendicular to the incident plane. Two crystal orientations were considered: I) c-axis of sample parallel and II) perpendicular to the incidence plane of beams which are referred as case I, and case II respectively. A continuous-wave Nd: YVO<sub>4</sub> laser operating at 532 nm with a coherent length ~10 cm and an output optical intensity of 0.69 W/cm<sup>2</sup> was used.

According to the two-wave coupling setup the photorefractive gain involving the incidence angle and/or grating spacing is given by

$$\Gamma = \frac{2\pi n_o^3 r_{13}}{\lambda \cos \theta} E_q \sqrt{\frac{E_D^2 + E_{PH}^2}{(E_D + E_q)^2}} \quad (1)$$

where  $n_o$  and  $n_e$  are the ordinary and extraordinary refractive indices for case I and II respectively,  $r_{13}$  is the effective linear electro-optic coefficient,  $\lambda$  is the light wavelength,  $\theta$  is the angle between one of the beams and the incidence face normal,  $E_q = qN^+ / 2\pi\epsilon_0$  is the trap-limited saturation field,  $E_D = 2\pi K_B T / qA$  is the diffusion field and  $E_{PH} = p\gamma_k N_A / q\mu s (N_D - N_A)$  is the bulk photovoltaic electric field. As is usual,  $q$  is the elementary charge,  $N_A$  is the density of acceptors,  $N_D$  is the density of donors,  $N^+ = N_A(N_D - N_A) / N_D$  is called the effective trap density,  $A$  is the grating spacing,  $\epsilon$  is the dielectric constant of material,  $\epsilon_0$  is the vacuum permittivity,  $K_B$  is the Boltzmann constant,  $T$  is the absolute temperature,  $p$  is an equivalent photovoltaic constant,  $\gamma_k$  is the recombination constant,  $\mu$  is the charge mobility, and  $s$  is the cross section for photoexcitation. Each parameter of the right-hand side of equation for  $E_{PH}$  is usually considered a constant.

## 3. Results

A large dependence of photorefractive effect on c-axis orientation for Mg: LiNbO<sub>3</sub> has been observed. Despite that Mg content is above threshold, the photorefractive response of this host persists if the c-axis is perpendicular to the incidence plane of beams in the two-wave mixing setup, whereas an optical-damage resistance greatly increases if Mg content is below threshold. Accordingly, this suggests that, besides photorefractive applications, Mg: LiNbO<sub>3</sub> can be used in anharmonic-oscillator-type nonlinear optical phenomena, in which the photorefractive response can be inhibited due to its anisotropic photorefractive only by selecting a suitable crystal orientation. Lastly, it has been proposed one model which takes into account a dependence of photovoltaic electric field on grating spacing, and an estimation of bulk photovoltaic field has also been carried out.

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